

Proc. Eurosensors XXIV, September 5-8, 2010, Linz, Austria

## MIS – Field Effect Sensors for Low Concentration of H<sub>2</sub>S for Environmental Monitoring

L.N. Kalinina<sup>a</sup>, A.V. Litvinov<sup>a</sup>, I. N. Nikolaev<sup>a</sup>, N.N. Samotaev<sup>a,\*</sup>

<sup>a</sup>*Physics of solid state and nanosystems department, National Research Nuclear University MEPhI, Kashirskoe shaussee 31, Moscow, 115409, Russian Federation*

---

### Abstract

It was found, that Metal Insulator Semiconductor Field Effect (MIS-FE) sensors with structures Pd-Si<sub>3</sub>N<sub>4</sub>-SiO<sub>2</sub>-Si and Pd-Ta<sub>2</sub>O<sub>5</sub>-SiO<sub>2</sub>-Si have sufficient concentration resolution to H<sub>2</sub>S gas and acceptable response time in mixture of H<sub>2</sub>S gas with air. Results of MIS-FE gas sensor operation in periodic regime are presented and allow us to be sure, that low detection level of H<sub>2</sub>S for MIS-FE sensor with Ta<sub>2</sub>O<sub>5</sub>-SiO<sub>2</sub> insulator is of about 5 ppb.

© 2010 Published by Elsevier Ltd.

*Keywords:* Field effect; gas sensor; hydrogen sulphide.

---

### 1. Introduction

H<sub>2</sub>S gas measurement in air is a very specific problem because hazardous concentration for human health is very low (for residence area is around 5 ppb and 14 ppm for working zone according to Russian standard of environmental protection); ppb-level delectability is not achieved for usual liquid electrochemical sensors, and also there are several important applications, where these sensors non-applicable because of short life time and extremely working condition such as humidity extremes (very dry or too much humid atmosphere), temperature drop or operation under permanently high concentration of H<sub>2</sub>S. Therefore, the purpose of this work was the creation of inexpensive and simple device for low H<sub>2</sub>S concentration measurement based on chip solid state gas sensor.

### 2. Experiment

To block necessary ppb - ppm ranges H<sub>2</sub>S concentrations we have developed in these work two types of MIS-FE sensors with structure Pd-Ta<sub>2</sub>O<sub>5</sub>-SiO<sub>2</sub>-Si for ppb and Pd-Si<sub>3</sub>N<sub>4</sub>-SiO<sub>2</sub>-Si for ppm ranges concentration measurement [1]. Thin film of palladium of these structures was deposited by laser technical [2]. The photo of substrate after

---

\* Corresponding author. Tel.: +7-495-5858273; fax: +7-495-343-9820.  
*E-mail address:* samotaev@mail.ru.

palladium laser deposition, Atomic Force microscope (AFM) imagination morphology of Pd gate MIS-FE structures are presented in fig.1.

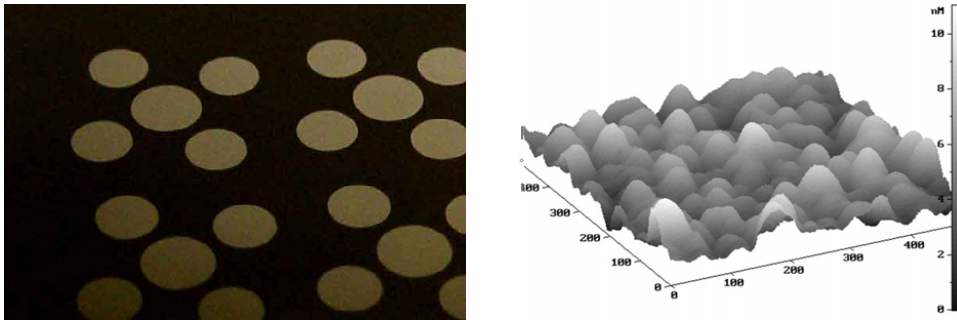


Fig. 1. (a) Photo of Si substrate with laser deposit Pd gates on insulator before cutting on sensor's chips; (b) AFM photo of Pd thin film used as a gate in MIS-FE structures. Area on the AFM photo is 500×500 nm

The sensors were operated in constant heating regime with temperature around 100 °C suitable for H<sub>2</sub>S gas detection. In order to heat chip with MIS-FE structure a resistive heater was integrated under chip. The average consumption power of that assemblage was equal to 500 mW. Photo of assembling are presented in fig.2 (a).

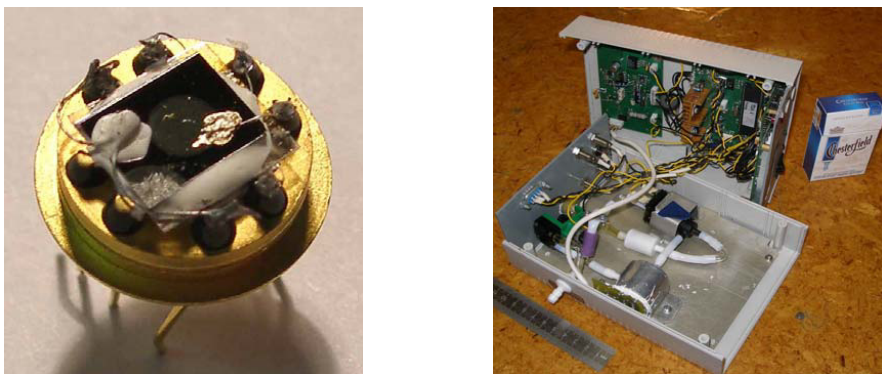


Fig. 2. (a) Photo of MIS-FE sensor chip bonded in TO-8 package. Diameter of the package is equal to ~ 10 mm, chip size is ~ 6.0 × 6.0 × 0.25 mm; (b) Photo of unsealed H<sub>2</sub>S gas measurement device using MIS-FE gas sensing element. Front side – air-driven setup with two channels measuring system, back side – electronic controller.

For the determination of MIS-FE sensors cross sensitivity to different gases presented in tab. 1, were computer controlled system equipped with mass-flow controller produced gas mixture with dry air. In order to improve the precision and to protect the sensor from the influence of interfering gases we used two channels measuring system with gas filter selective to H<sub>2</sub>S, working in periodic regime with 20 minute duration (operating 5 minutes with pure channel and 15 minutes with filter). Photo of unsealed measuring system are presented in fig.1 (b).

The response curves of the sensors to H<sub>2</sub>S are presented in fig.3 and quantitative sensitivity to different gases as a shift of C-V characteristics are presented in tab.1 (appendix A). Since the sensitivity of the sensors to H<sub>2</sub>S gas is high and flow creation of this sub-ppb range concentration gas mixture was difficult, we determined the low

متن کامل مقاله

دریافت فوری ←

**ISI**Articles

مرجع مقالات تخصصی ایران

- ✓ امکان دانلود نسخه تمام متن مقالات انگلیسی
- ✓ امکان دانلود نسخه ترجمه شده مقالات
- ✓ پذیرش سفارش ترجمه تخصصی
- ✓ امکان جستجو در آرشیو جامعی از صدها موضوع و هزاران مقاله
- ✓ امکان دانلود رایگان ۲ صفحه اول هر مقاله
- ✓ امکان پرداخت اینترنتی با کلیه کارت های عضو شتاب
- ✓ دانلود فوری مقاله پس از پرداخت آنلاین
- ✓ پشتیبانی کامل خرید با بهره مندی از سیستم هوشمند رهگیری سفارشات